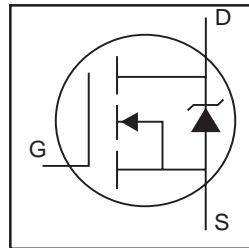


HEXFET® Power MOSFET Die in Wafer Form



40V
Size 4.0
 $R_{DS(on)} = 0.0029\Omega$
6" Wafer

Electrical Characteristics (Wafer Form)

Parameter	Description	Guaranteed (Min/Max)	Test Conditions
$V_{(BR)DSS}$	Drain-to-Source Breakdown Voltage	40V Min.	$V_{GS} = 0V, I_D = 250\mu A$
$R_{DS(on)}$	Static Drain-to-Source On-Resistance	2.9m Ω Max.	$V_{GS} = 10V, I_D = 45A$
$V_{GS(th)}$	Gate Threshold Voltage	2.0V Min., 4.0V Max.	$V_{DS} = V_{GS}, I_D = 250\mu A$
I_{DSS}	Drain-to-Source Leakage Current	25 μA Max.	$V_{DS} = 40V, V_{GS} = 0V, T_J = 25^\circ C$
I_{GSS}	Gate-to-Source Leakage Current	$\pm 200nA$ Max.	$V_{GS} = \pm 20V$
T_J	Operating Junction and	-55 $^\circ C$ to 175 $^\circ C$ Max.	
T_{STG}	Storage Temperature Range		

Mechanical Data

Nominal Back Metal Composition, Thickness:	Cr-NiV-Ag (1kA°-2kA°-2.5kA°)
Nominal Front Metal Composition, Thickness:	100% Al (0.008 mm)
Dimensions:	.170" x .230" [4.32 mm x 5.84 mm]
Wafer Diameter:	150 mm, with 100 flat
Wafer Thickness:	0.356 mm \pm 0.025 mm
Relevant Die Mechanical Drawing Number	01-5384
Minimum Street Width	0.109 mm
Reject Ink Dot Size	0.51 mm Diameter Minimum
Recommended Storage Environment:	Store in original container, in dessicated nitrogen, with no contamination
Recommended Die Attach Conditions:	For optimum electrical results, die attach temperature should not exceed 300 $^\circ C$

Die Outline

NOTES:

- ALL DIMENSIONS ARE SHOWN IN MILLIMETERS [INCHES].
- CONTROLLING DIMENSION: [INCH].
- LETTER DESIGNATION:
S = SOURCE SK = SOURCE KELVIN E = EMITTER
G = GATE IS = CURRENTSENSE
- DIMENSIONAL TOLERANCES:
BONDING PADS: < 0.635 TOLERANCE = +/- 0.013
WIDTH < [.0250] TOLERANCE = +/- [.0005]
& > 0.635 TOLERANCE = +/- 0.025
LENGTH > [.0250] TOLERANCE = +/- [.0010]
OVERALL DIE: < 1.270 TOLERANCE = +/- 0.102
WIDTH < [.050] TOLERANCE = +/- [.004]
& > 1.270 TOLERANCE = +/- 0.203
LENGTH > [.050] TOLERANCE = +/- [.008]
- UNLESS OTHERWISE NOTED ALL DIE ARE GEN II